10/535533 JC20 Rec'd PCT/PTO 19 MATE 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	HADA, et al.	Group Art Unit Unknown
Int'l App. No.	:	PCT/JP03/15347)	
Int'l Filing Date	:	December 1, 2003	
For	:	METHOD OF FORMING RESIST PATTERN, POSITIVE RESIST COMPOSITION, AND LAYERED PRODUCT	
Examiner	:	Unknown)	

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is an Information Disclosure Statement by Applicant (PTO/SB/08 equivalent) listing five (5) references to be considered by the Examiner. Also enclosed are five (5) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed within three months of the filing date, with an RCE or before receipt of a first office action after an RCE and no fee is required.

The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.

LP

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Multiple sheets used when necessary) Int'l Application No. PCT/JP03/k3 3 / 5 3 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Application No. PCT/JP03/k3 3 / 5 3 5 5 3 Int'l Filing Date December 1, 2003 First Named Inventor Hideo HADA Art Unit Unknown (Multiple sheets used when necessary) Examiner Unknown

SHEET 1 OF 1

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear

Attorney Docket No.

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹
	1.	JP 01-307228	12/12/89	Hitachi Ltd., Hitachi VIsi Eng Corp	(English Abstract Only)	Х
	2.	JP 04-364021	12/16/92	Sumitomo Electric Ind Ltd.	(English Abstract Only)	Х
	3.	JP 05-166717	07/02/93	Mitsubishi Electric Corp	(English Abstract Only)	Х
	4.	JP 05-241348	09/21/93	Hitachi Ltd.	(English Abstract Only)	Х
	5.	JP 2002-162745	06/07/02	Tokyo Ohka Kogyo Co Ltd.	(English Abstract Only)	Х

NON PATENT LITERATURE DOCUMENTS				
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ¹	

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